

PAIDC

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>091705,274</u>	Prepared by <u>NH</u>	Tracking Number <u>05891187</u>	
Examiner-GAU <u>Coleman-2823</u>	Date <u>2-16-4</u>	Week Date <u>01/19/04</u>	
	No. of queries <u>1</u>	<u>IFW</u>	

## JACKET

a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

## SPECIFICATION

- a. Page Missing
- b. Text Continuity
- c. Holes through Data
- d. Other Missing Text
- e. Illegible Text
- f. Duplicate Text
- g. Brief Description
- h. Sequence Listing
- i. Appendix
- j. Amendments
- k. Other

## CLAIMS

- a. Claim(s) Missing
- b. Improper Dependency
- c. Duplicate Numbers
- d. Incorrect Numbering
- e. Index Disagrees

f. Punctuation

- g. Amendments
- h. Bracketing
- i. Missing Text
- j. Duplicate Text
- k. Other

## MESSAGE

Claim 11 ends with a semicolon.  
Please Advise.

Thank you

initials NH

## RESPONSE

Typo corrected.

initials JBH

10. The method of claim 9, further including before forming the protruding region, forming a masking material above the first epi layer.

JBH  
2-26-04  
11. The method of claim 10, further including forming a mask on the masking material at a location for the trench/.

12. The method of claim 11, wherein the mask is a photoresist material.

13. The method of claim 11, wherein forming the protruding region further includes performing an etch step to remove the masking material where the mask is absent to form the opening.

14. The method of claim 9, wherein forming the second epi layer includes using a selective epi growth process.

15. The method of claim 9, wherein forming the second epi layer further includes forming the second epi layer over the protruding region.

16. The method of claim 15, wherein forming the second epi layer over the protruding region includes using a blanket epi growth process.